









SM-570



- Mainly used for cleaning the micro-dust particles on the surface of camera module, Holder, CMOS body, Wafer, etc., through high-pressure pure water rinsing and water-gas two-fluid cleaning
- HMI, one-button operation, complete the entire cleaning process automatically
- Integrated cleaning system
- Mirror stainless steel structure, and large observation window, practical and beautiful
- Professional design, two-stage FFU air filtration, to ensure the open loop discharge of DI water and air, no secondary pollution
- Small and compact appearance design, small floor area, convenient deployment
- Low energy consumption and low operating noise
- The entire system is monitored by instrument, safe and stable operation
- The air is automatically filtered to ensure the cleaning effect